



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ATTY.'S DOCKET: 00 P 9031 US

In re the application of:
Helmut Tews et al.

Serial No.: 09/714,356

Filing Date: November 16, 2000

Title: NITROGEN IMPLANTATION USING
A SHADOW EFFECT TO CONTROL
GATE OXIDE THICKNESS IN
DRAM SEMICONDUCTORS

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) Group Art: 2813
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) Examiner: Chen, Jack SJ.
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AMENDMENT UNDER 37 CFR §1.115

Honorable Commissioner of Patents and Trademarks
Washington, D.C. 20231

Sir:

In reply to the Office Action mailed October 4, 2002,
which rejected the claims in the above-identified patent
application, applicants respectfully request reconsideration
based on the amendments hereinafter set forth.

IN THE ABSTRACT:

A new abstract page is submitted herewith on a separate
sheet. As revised, the new abstract is: within the range of 50
to 150 words; is devoid of legal phraseology and now satisfies
the abstract requirements set forth in MPEP.

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